## Claims

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- Process for the treatment or pre-treatment of parts, profiles, strips, sheets and/or wires with metallic surfaces, in which at least 5% of these surfaces consist of aluminium and/or at least one aluminium alloy, and the other metallic surfaces can optionally consist predominantly of iron alloys, zinc and/or zinc alloys, with an acidic, aqueous solution containing fluoride, zinc and phosphate, characterised in that the dissolved contents in the phosphating solution are as follows:
  - sodium: virtually none or in the concentration range of 0.04 to less than 2 g/l,
  - potassium: virtually none or in the concentration range of 0.025 to 2.5 g/l,
  - sodium and potassium together: in the concentration range of 0.025 to 2.5 g/l as sodium, the potassium content being converted to sodium on a molar basis,
  - zinc: in the concentration range of 0.2 to 4 g/l,
  - phosphate: in the concentration range of 4 to 65 g/l, calculated as PO<sub>4</sub>,
  - free fluoride: in the concentration range of 0.03 to 0.5 g/l,
  - total fluoride: in the concentration range of0.1 to 5 g/l and
- optionally nitrate: at least 0.2 g/l, wherein a zinc-containing phosphate film is deposited on the metallic surfaces with a coating weight in the range of 0.5 to 10 g/m<sup>2</sup>.
- 35 2. Process according to claim 1, characterised in that the contents of dissolved aluminium in the

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phosphating solution are in the concentration range of 0.002 to 1 g/l.

- 3. Process according to claim 1 or 2, characterised in that the total content of silicon complex fluoride and boron complex fluoride together in the phosphating solution is 0.01 to 8 g/l optionally converted on a molar basis as SiF<sub>6</sub>, it being unnecessary for the two groups of fluoride complexes to occur at the same time.
  - 4. Process according to one of the above claims, characterised in that the contents of complex bound fluoride in the phosphating solution are 0.01 to 8 g/l, calculated on a molar basis as  $SiF_6$ .
  - 5. Process according to one of the above claims, characterised in that the contents dissolved in the phosphating solution are as follows:
- sodium: in the concentration range of 0.050 to 2 g/l,

potassium: virtually none or in the concentration range of 0.030 to 1.5 g/l,

- sodium and potassium: in the concentration range of 0.025 to 1.5 g/l as sodium, potassium being converted to sodium on a molar basis, silicon complex fluoride: in the concentration range of 0.01 to 4 g/l and/or
- boron complex fluoride: in the concentration range of 0.01 to 4 g/l, calculated as  $SiF_6$  and  $BF_4$  respectively.
- 6. Process according to one of the above claims, characterised in that the dissolved contents in the phosphating solution are as follows: sodium: virtually none or in the concentration range of 0.060 to 1.8 g/l,

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potassium: in the concentration range of 0.035 to 1.4 g/l, sodium and potassium: in the concentration range of 0.05 to 2 g/l as sodium, potassium being converted to sodium on a molar basis, silicon complex fluoride: in the concentration range of 0.02 to 1 g/l and/or boron complex fluoride: in the concentration range of 0.02 to 3 g/l, calculated as SiF<sub>6</sub> and BF<sub>4</sub> respectively.

- 7. Process according to one of the above claims, characterised in that the dissolved contents in the phosphating solution are as follows:
- nickel: virtually none or in the range of 0.001 to 3 g/l and/or manganese: virtually none or in the range of 0.002 to 5 g/l.
- 20 8. Process according to one of the above claims, characterised in that the dissolved contents in the phosphating solution are as follows:

  dissolved iron<sup>2+</sup> ions: virtually none or in the concentration range of 0.005 to 3 g/l and/or complexed iron<sup>3+</sup> ions: virtually none or in the concentration range of 0.005 to 1 g/l.
- 9. Process according to one of the above claims, characterised in that the dissolved contents in the phosphating solution are as follows: silver: virtually none or in the concentration range of 0.001 to 0.080 g/l and/or copper: virtually none or in the concentration range of 0.001 to 0.050 g/l.

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- 10. Process according to one of the above claims, characterised in that the dissolved contents in the phosphating solution are as follows: titanium: virtually none or in the concentration range of 0.001 to 0.200 g/l and/or zirconium: virtually none or in the concentration range of 0.001 to 0.200 g/l.
- 11. Process according to one of the above claims,

  10 characterised in that the dissolved contents in the phosphating solution are as follows:

  ammonium: virtually none or in the concentration range of 0.01 to 50 g/l and/or nitrate: virtually none or in the concentration range of 0.01 to 30 g/l.
  - 12. Process according to one of the above claims, characterised in that the dissolved contents in the phosphating solution are as follows: sulfate: virtually none or in the concentration
- sulfate: virtually none or in the concentration range of 0.005 to 5 g/l and/or chloride: virtually none or in the concentration range of 0.020 to 0.5 g/l.
- 25 13. Process according to one of the above claims, characterised in that the phosphating solution contains at least one accelerator selected from the group of compounds or ions based on nitrogen-containing compounds in the concentration range of 0.01 to 8 g/l, chlorate in the concentration range of 0.01 to 6 g/l, hydroxylamine in the concentration range of 0.01 to 3 g/l,
- peroxide, including water-soluble organic peroxide, in the concentration range of 0.001 to 0.200 g/l, calculated as  $H_2O_2$ ,

with contents in the concentration range given.

- 14. Process according to one of the above claims, characterised in that the content of magnesium in the phosphating solution is no more than 1 g/l, preferably no more than 0.15 g/l.
- 15. Process according to one of the above claims, characterised in that no or almost no precipitation product based on aluminium fluorocomplexes of ammonium, alkali and/or alkaline earth metal is deposited on the metallic surface, below the phosphate film and/or between the zinc phosphate crystals in the phosphate film on the surfaces of aluminium and/or at least one aluminium alloy phosphated in this way.
- 16. Process according to one of the above claims, characterised in that the pH value is maintained in the range of 2 to 4.
  - 17. Process according to one of the above claims, characterised in that the content of free acid determined with KCl is in the range of 0.3 to 6 points, the content of dilute total acid is in the range of 8 to 70 points and/or the content of total acid according to Fischer is in the range of 4 to 50 points.
  - 30 18. Process according to one of the above claims, characterised in that the phosphate coating is applied at 20 to 70°C.
  - 19. Use of the substrates coated by the process
    35 according to at least one of claims 1 to 18 in
    strip production, for the production of components
    or body parts or pre-assembled elements in the

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automotive or aircraft industry, in the construction industry, in the furniture industry, for the production of equipment and plant, particularly domestic appliances, measuring instruments, control devices, testing devices, structural elements, claddings and small parts; as wire, wire wrap, wire mesh, sheet, cladding, screening, a car body or part of a car body, as part of a vehicle, trailer, motorhome or aircraft, as an electronic or microelectronic component, as a cover, housing, lamp, light, traffic light element, a piece of furniture or a furniture part, part of a domestic appliance, stand, profile, moulded part with complicated geometry, crash barrier, radiator or fence element, bumper, part consisting of or with at least one pipe and/or a profile, window-, door- or bicycle frame or as a small part, such as e.g. a screw, nut, flange, spring or spectacle frame.

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